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Suppressing the formation of NO_x and N₂O in CO₂/N₂ dielectric barrier discharge plasma by adding CH₄: scavenger chemistry at work†

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The need for carbon negative technologies led to the development of a wide array of novel CO₂ conversion techniques. Most of them either rely on high temperatures or generate highly reactive O species, which can lead to the undesirable formation of NO_x and N₂O when the CO₂ feeds contain N₂. Here, we show that, for plasma-based CO₂ conversion, adding a hydrogen source, as a chemical oxygen scavenger, can suppress their formation, *in situ*. This allows the use of low-cost N₂ containing (industrial and direct air capture) feeds, rather than expensive purified CO₂. To demonstrate this, we add CH₄ to a dielectric barrier discharge plasma used for converting impure CO₂. We find that when adding a stoichiometric amount of CH₄, 82% less NO₂ and 51% less NO are formed. An even higher reduction (96 and 63%) can be obtained when doubling this amount. However, in that case the excess radicals promote the formation of by-products, such as HCN, NH₃ and CH₃OH. Thus, we believe that by using an appropriate amount of chemical scavengers, we can use impure CO₂ feeds, which would bring us closer to 'real world' conditions and implementation.

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1. Introduction

The global challenge of climate change and the need for carbon negative technologies have sparked research interest in a wide variety of techniques capable of converting CO₂.^{1–6} This CO₂ can be captured either from major emission sources or—preferably, in the long run— from air, through direct air capture (DAC).⁷ Numerous analyses and comparisons between different technologies have been made in the literature; however, they all overlook a key aspect that has major consequences, *i.e.* the fact that lab-scale studies generally use pure gases (99.999% purity), whereas industrial gases (with some exceptions) usually contain N₂. Purification is one option, but an energy intensive, and thus costly one.⁸ Another—more practical—option is to directly use these impure gases.

However, this option comes with an important obstacle. Most novel technologies under consideration for the conversion of CO₂ into CO and O₂ either require high temperatures (*e.g.*, solar thermochemical and catalytic thermochemical

conversion) or create highly reactive O species *in situ* (*e.g.*, electrochemical, photochemical and plasmachemical conversion).¹ As a result, the risk of producing nitrogen oxides (NO_x) and nitrous oxide (N₂O) is real.^{9,10} In combustion science, the formation of NO_x and N₂O is a well-understood phenomenon.^{11,12} Among the three major NO_x formation mechanisms (*i.e.*, thermal NO_x (Zel'dovich), prompt NO_x, and fuel NO_x), the thermal mechanism consistently produces NO_x, as long as O₂ and N₂ coexist under high temperature conditions (>1900 K).¹¹ N₂O, on the other hand, is not a major by-product in combustion processes, except for fluidized bed combustion.¹² When released in the atmosphere, these compounds lead to severe air pollution, such as smog and acid rain, and they are responsible for the formation of tropospheric ozone.¹³ With respect to global warming, the production of N₂O, in any CO₂ conversion process, cancels out the carbon negative effect of any CO₂ converted, since N₂O is 298 times more potent as a greenhouse gas.¹³ This is why NO_x and N₂O emissions are so strictly regulated worldwide.

Despite the potential risk of producing unwanted NO_x and N₂O during the conversion of impure CO₂ feeds containing N₂, almost no research has been performed in this area, for the novel technologies that are being considered to convert CO₂. It stands, without doubt, that this is an important issue, as additional deNO_x post-treatment, or more severe CO₂ pre-purification steps, will have a negative effect on the energy and cost balance of these CO₂ conversion technologies. In previous studies, we reported that, for non-thermal plasma technology—one of the most promising technologies for the conversion of

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CO₂ (ref. 1)—the presence of N₂ indeed causes the aforementioned formation of NO_x and N₂O.^{9,10}

Here, we explore a potential solution to prevent the formation of NO_x and N₂O, *in situ*, during the plasmachemical conversion of CO₂. A well-known solution from combustion science has been the addition of more fuel (eq. to a higher fuel-to-air ratio).¹³ Despite the fact that we work under experimental conditions that are very different from those in combustion science, we can justify using a similar approach, based on the results obtained in our previous studies.^{9,14,15} We already know that the addition of a hydrogen source to non-thermal pure CO₂ plasmas can trap free O species, *in situ*.¹⁴ And exactly these free O species are responsible for the NO_x and N₂O production pathways in non-thermal plasmas.⁹ Therefore, here we introduce the use of a hydrogen source, CH₄, as a chemical oxygen scavenger to suppress the formation of NO_x and N₂O, *in situ*, during the conversion of CO₂ mixtures containing N₂, in a dielectric barrier discharge (DBD) plasma.

2. Materials and methods

Experiments were carried out in a coaxial DBD plasma reactor operating at room temperature and atmospheric pressure. A stainless steel mesh (high voltage electrode) was wrapped over the outside of a quartz tube, and a stainless steel rod (ground electrode) was placed at its centre. Feed gases were composed of CO₂, N₂ and CH₄ (Air Liquide, Alphagaz 1, 99.999%), and each flow rate was controlled using a mass-flow controller (Bronkhorst, EL-Flow select F-210CV). The DBD reactor was powered by an AC high-voltage power supply (AFS, custom made), and the applied voltage and electrical current were sampled using a four-channel digital oscilloscope (Picotech, PicoScope 64201). Finally, Fourier transform infrared spectroscopy (FTIR; Thermo Fischer Scientific, Nicolet 380) was used to study the effects of the addition of CH₄ on the formation of N₂O and NO_x compounds (*i.e.*, NO, NO₂, N₂O₃ and N₂O₅). A detailed description of the set-up and experimental conditions can be found in Section 1 of the ESI.†

2.1. CH₄ as a chemical oxygen scavenger to suppress NO_x production

Despite the many advantages offered by plasma technology for the conversion of CO₂, two main challenges remain:¹

(1) Separation: the output of a plasma reactor consists of a homogeneous gas mixture; in the case of plasma-based CO₂ conversion, it yields a mixture of CO and O₂ (and any unreacted CO₂) that is very difficult (and thus energy-intensive) to separate by conventional methods;

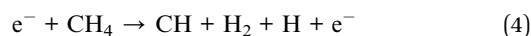
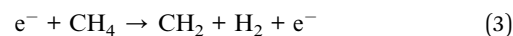
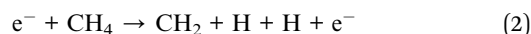
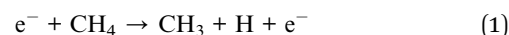
(2) Impurities: the presence of other gases (even those generally considered to be chemically inert) influences both the physical properties of the plasma and its chemistry; in the case of plasma-based CO₂ conversion, the presence of N₂ results in the undesired formation of NO_x and N₂O.

Here, we show how focussing on the plasma chemistry can help us to simultaneously find answers to both the separation

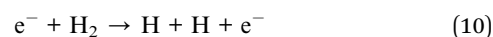
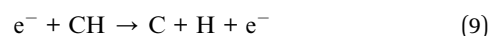
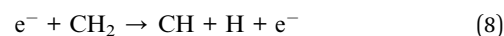
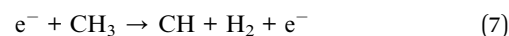
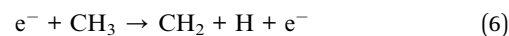
and impurity issues, in the case of a DBD plasma reactor used for the conversion of an impure CO₂ feed containing N₂.

As a baseline case, we studied a DBD operating at a specific energy input (SEI) of 12 kJ L⁻¹, for a 1 : 1 mixture of CO₂ : N₂. Detailed experimental and modelling results for a wide variety of CO₂ : N₂ mixing ratios were discussed in a previous study,⁹ with the highest NO_x production occurring for the 1 : 1 case, which is the main reason why we chose to further explore that condition first. A chemical analysis revealed that NO_x species are formed through several pathways in the presence of N₂, during plasma processing of CO₂. The main formation mechanism, for all the different NO_x species, starts with a reaction involving O (or O₂) and N (or N₂(A³)) (see also Section 2.2 below).⁹ This observation is complementary with that made in a previous study, which showed that it was possible to chemically trap oxygen species, *in situ*, by adding a hydrogen source.¹⁴ Additionally, another separate study showed that when O and H radicals are present in a plasma, their natural tendency is to form H₂O.¹⁵ Therefore, by combining these three observations, it becomes apparent that we are presented with a ‘chemical opportunity’. We hypothesize, based on chemical analyses from these prior studies, that the addition of a small stoichiometric amount of a hydrogen source to a CO₂ : N₂ mixture should be sufficient for trapping the O radicals with H species to form OH and H₂O, before the N species can react with the O species and form NO_x and N₂O (Fig. 1).

To verify the validity of our hypothesis that an effective chemical oxygen scavenger can prevent the formation of NO_x and N₂O, we investigated the effects of using CH₄ as a hydrogen source. Some of the most important plasmachemical reactions leading to the formation of the desired hydrogen radicals are the following electron impact dissociation reactions of CH₄:



These radicals react further through subsequent electron impact dissociation reactions:



The most important electron impact dissociation and excitation reactions with CO₂ and N₂ are:

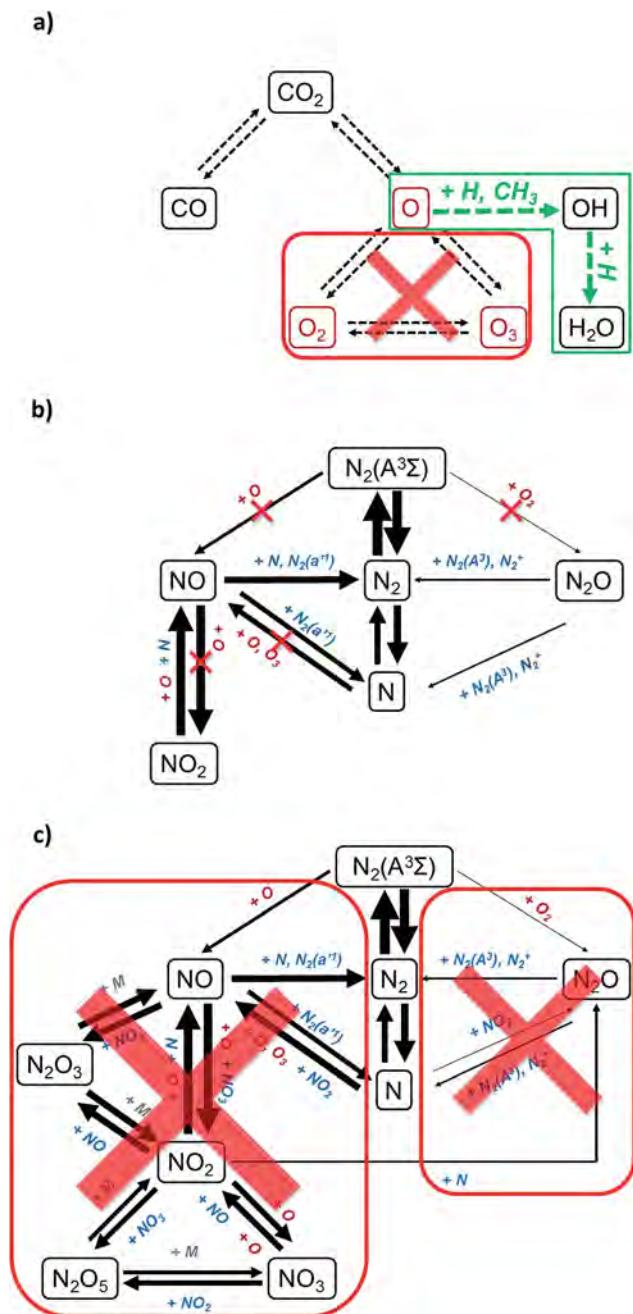
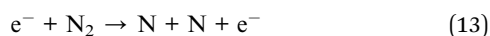
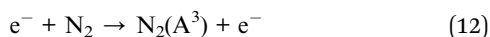
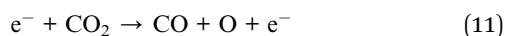
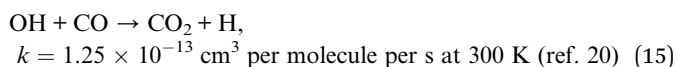
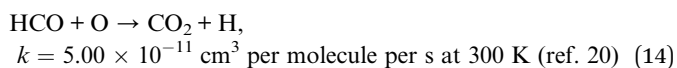


Fig. 1 Simplified reaction scheme illustrating the suppression of the main pathways of the NO_x and N₂O chemistry through the addition of CH₄. Reaction pathways starting from CO₂ show the *in situ* trapping of O by H species (a); initiation of the NO_x chemistry, indicating which pathways are eliminated by the *in situ* trapping of O (b); complete overview of the NO_x and N₂O chemistry to be suppressed by the scavenging of oxygen (c). Original reaction schemes have been adapted from ref. 9.



For more details on these and other types of plasmachemical (electron impact) reactions refer to the existing literature and databases.^{1,9,16–19}

We varied the CH₄ addition from 0.1 up to 2.0 mol% of the total CO₂ : N₂ mixture, for a DBD under operating conditions similar to those in the baseline case. It is important to note that the introduction of other components influences the physics of the plasma and its chemistry, especially with a species like CH₄, which results in a cascade of reactive compounds, including H and CH_x radicals. As a result, the electron density and temperature, which affect the conversions, can be altered significantly. Additionally, the conversion of CO₂ can also decrease, due to additional back reactions to CO₂, such as:



This effect was observed in a previous study, in which adding 2 mol% CH₄ to pure CO₂ yielded a drop in the relative conversion of CO₂ by ~10%.¹⁴

In Fig. 2, we can clearly see a decrease of both the NO (1875 cm⁻¹) and NO₂ (1599 cm⁻¹) peaks, when adding CH₄ to the mixture, with the NO peak showing the biggest initial decrease, and the NO₂ peak showing a stronger overall response (see also Fig. 3a). The NO peak decreases by 42% upon adding 0.1 mol% CH₄, by 51% with 1.0 mol%, and by 63% with 2.0 mol% CH₄ added. The NO₂ peak, on the other hand, decreases by 32% upon adding 0.1 mol% CH₄, by 82% with 1.0 mol%, and by 96% with 2.0 mol% CH₄ added.

Due to a complete overlap of the CH₄ peaks, we cannot determine whether the N₂O₃ (1309 cm⁻¹) and/or N₂O₅ (1245 cm⁻¹) peaks decrease, upon addition of CH₄. Nevertheless, this would be a logical consequence, since N₂O₃ and N₂O₅ are secondary reaction products from NO and NO₂ (Fig. 1).

The N₂O (2233 cm⁻¹) peak, on the other hand, seems to increase when more CH₄ is added (Fig. 2). This seems in contrast with a severe reduction of the formation of O₂, which is necessary for the production of N₂O from N₂(A³) (Fig. 1). Therefore, there are two options: either the N₂O concentration is indeed increasing or its decrease is masked in the FTIR spectra due to interference of other compounds with a similar absorption of the IR frequency (both options are further discussed in Section 2.2).

Besides the decrease in NO and NO₂ peak intensities, some additional peaks started to emerge from the noise when we added 1 mol% CH₄ to the mixture (Fig. 2); they became clearly visible as we increased the CH₄ concentration to 2 mol%. The peak at 3334 cm⁻¹ corresponds to HCN;²¹ the peak at 1034 cm⁻¹ corresponds to CH₃OH;²¹ and the peak at 997 cm⁻¹ corresponds to NH₃.²¹ The HCN peak increases almost linearly, starting from 0.1 mol% CH₄, whereas the CH₃OH and NH₃ peaks only emerge clearly from the noise starting at 1.0 mol% of CH₄ added, and exhibit an exponential increase with further addition of CH₄, to 2 mol% (Fig. 3b).

The formation of these additional components indicates that adding more than 1 mol% CH₄ generates an excess of the

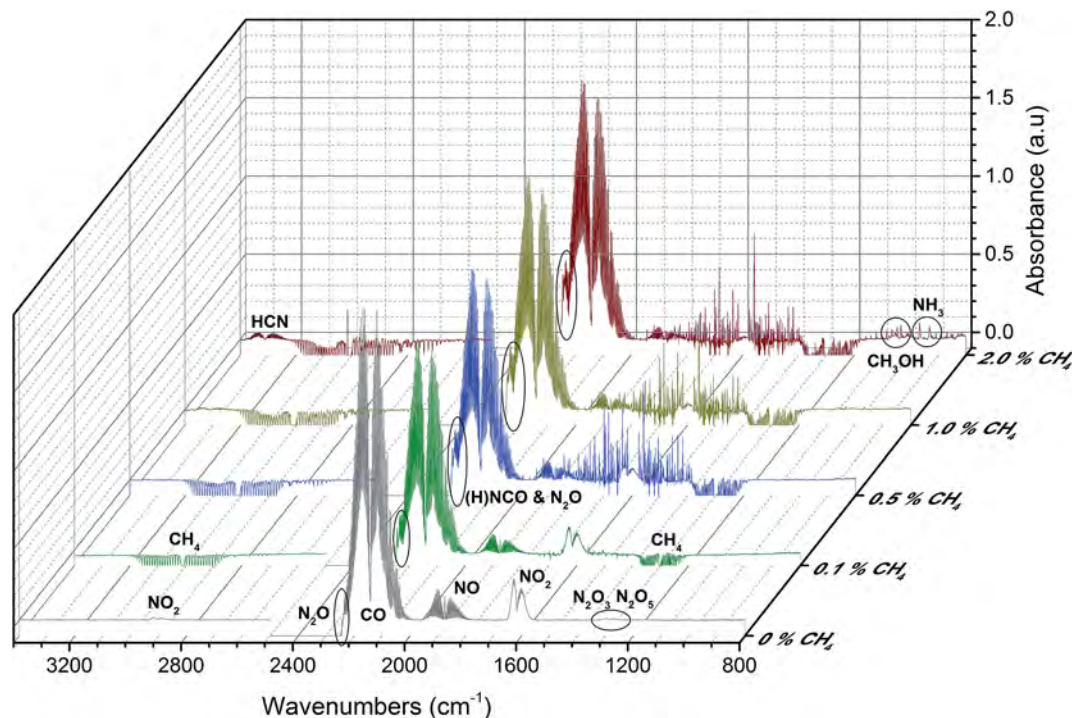
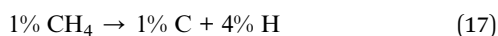
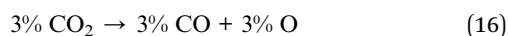


Fig. 2 FTIR spectra of a 1 : 1 mixture of CO₂ : N₂ with 0, 0.1, 0.5, 1.0 and 2.0 mol% CH₄ added. For clarity, the CO₂ peak has been removed. The negative absorbance of the CH₄ bands is due to the subtraction of the blank spectra obtained before turning on the plasma. Original spectra are provided in Section 2.3 of the ESI†

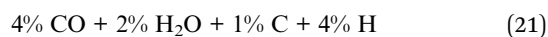
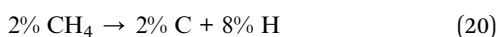
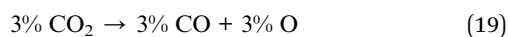
hydrogen source; most of the O species have been trapped into H₂O and the excess radicals produce some of the typical products that can be expected in a CH₄/N₂ mixture (NH₃ and HCN)¹⁷ and in a CH₄/CO₂ mixture (CH₃OH).^{18,22} This result is not surprising and consistent with the stoichiometric balance for adding 1 and 2 mol% CH₄.

By correcting the CO₂ conversion of 3.8% of the baseline case⁹ to 3% for the lowered conversion, upon addition of CH₄ (as well as to simplify the balance), and then adding 1 mol% CH₄ (which is almost completely converted, see Table S3 and Fig. S3 in the ESI†), we can construct the following balance:



In this case, the O radicals will readily recombine with the C radicals and form CO, and with the H radicals and form H₂O.

When adding 2 mol% CH₄, (16), (17) and (18) become:



Hence, besides forming CO and H₂O, the C and H radicals in excess will form other products, such as CH₃OH, HCN, NH₃ and

HNCO, as revealed in Fig. 2 and 3. From these stoichiometric balances, it is also clear that the use of CH₄ as a hydrogen source can lead to an increase in CO selectivity. Indeed, when increasing the CH₄ content from 0.1 to 2 mol% the CO peak in the FTIR spectra increases by 42% (see Fig. 2).

In theory the formation of these additional components should not be a major problem, unlike the NO_x formation we are aiming to inhibit, since CH₃OH, HCN and HNCO can be condensed from the CO stream, and for NH₃ efficient scrubbing systems exist.

2.2. Oxygen scavenging chemistry

The experimental results presented in Section 2.1 clearly show that the addition of CH₄ as a chemical oxygen scavenger does indeed suppress the formation of NO_x, *in situ*. The observed trends can be explained by looking at the different reaction rate coefficients of the most important reactions.

Without a hydrogen source, the main components of the mixture are the following: the unreacted CO₂ and N₂, the CO₂ electron impact dissociation products CO and O, and, to a very small extent, the N₂ electron impact dissociation product N and the electron impact excited metastable N₂(A³). However, due to its high dissociation energy threshold, the conversion of N₂ and thus the concentration of N is very low ($\sim 10^{17} \text{ cm}^{-3}$), for a DBD plasma.⁹ In addition, although the concentration of N₂(A³) is higher ($\sim 2 \times 10^{18} \text{ cm}^{-3}$), only $\sim 2\%$ ($\sim 4 \times 10^{16} \text{ cm}^{-3}$) takes part in the formation of NO_x, due to its fast quenching processes.⁹ For these main components, we can establish the following reaction chemistry, which recombines most of the O radicals to form O₂:

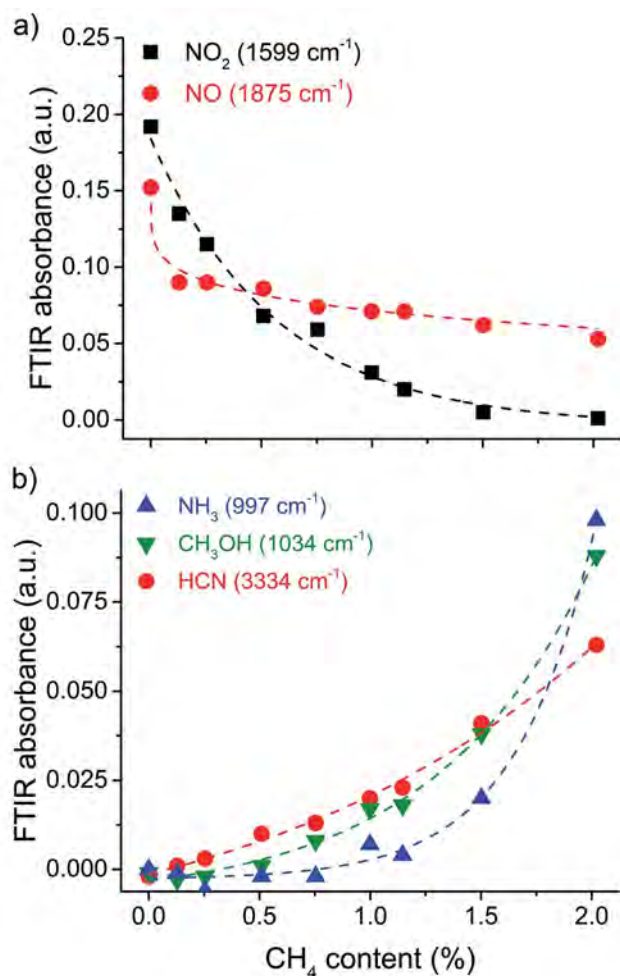
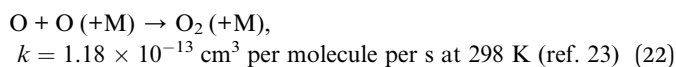
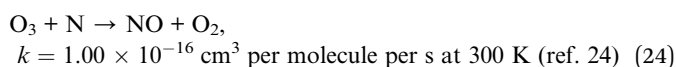
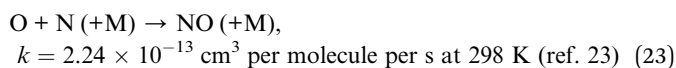


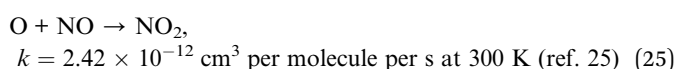
Fig. 3 FTIR absorbance for NO and NO₂ (a); and for NH₃, CH₃OH and HCN (b) as a function of the amount of CH₄ added to a 1 : 1 mixture of CO₂ : N₂ for a SEI of 12 kJ L⁻¹.



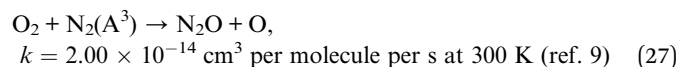
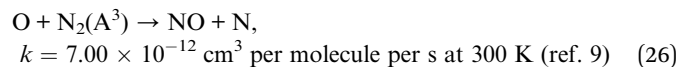
However, some of the O radicals, as well as O₃, react with the few N radicals (see Fig. 1):



Subsequently, some of the O radicals react with the formed NO:

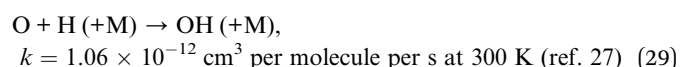
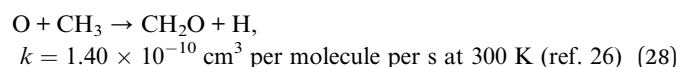


Additionally, the metastable N₂(A³) also reacts with the O radicals and O₂:

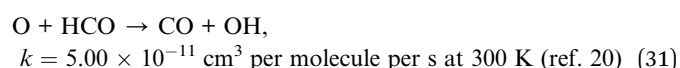
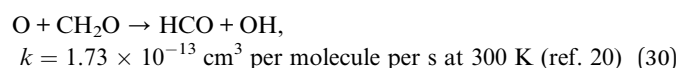


When a small amount (<2 mol%) of CH₄ is added as a hydrogen source, the main components of the mixture are the following: the unreacted CO₂ and N₂ (and to a minor extent CH₄), the CO₂ electron impact dissociation products CO and O, the N₂ electron impact dissociation product N (to a very small extent) and the electron impact excited metastable N₂(A³), and the CH₄ electron impact dissociation products CH_x and H.^{17,18} Up to 0.5 mol% of CH₄ added, the conversion of CH₄ is close to 100%, for 1 mol% of CH₄ added, the conversion is still 89%, but for 2 mol% of CH₄ added, the conversion decreases to 59% (see ESI Table S3 and Fig. S3†). To effectively trap the O radicals and to suppress the formation of NO_x and N₂O, *in situ*, the scavenging reactions need to be faster than reactions 22 to 27 described above. It is important to note that the reaction rate coefficients can only give us an indication of the speed of reaction, so the information presented above needs to be put in perspective. In order to determine the real, exact reaction rates, we would also need to know the densities of all the species and the various chemical equilibria involved. Those can be obtained through the development of a complete and extensive chemical kinetics model.

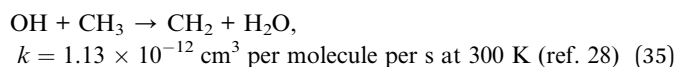
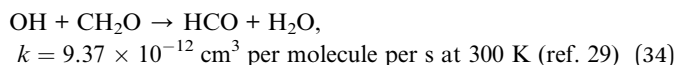
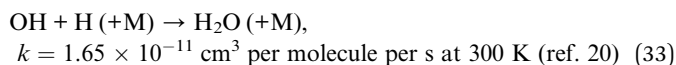
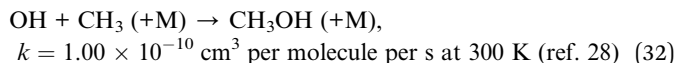
First, the rate coefficients for O radical scavenging reaction with H and CH₃ radicals (see below) are clearly in the same order and higher than those for the above reactions (22), (23) and (26). Furthermore, the concentrations of H and CH₃ radicals (~2.5 × 10¹⁷ to 5 × 10¹⁸ cm⁻³, based on the (nearly) full conversion of CH₄ at 0.1 to 2% CH₄ added) are higher than those of the N radicals (~10¹⁷ cm⁻³; see above) and available metastable N₂(A³) (~4 × 10¹⁶ cm⁻³; see above). Hence, these reactions are estimated to be faster, which means that H and CH₃ radicals are indeed effective chemical oxygen scavengers:



The CH₂O radical further reacts towards the formation of OH:



The formed OH radicals get rapidly trapped into H₂O and CH₃OH by subsequent reactions (32)–(35), some of them are even faster than the initial reactions (29)–(31) forming OH. This, in turn, enhances the formation of OH by Le Chatelier's principle, since these reactions rapidly remove the OH radicals from the mixture:



In general, all these chemical reactions ((28) to (35)) provide a clear indication of how the addition of CH_4 , as an oxygen scavenger, suppresses the formation of NO_x and possibly N_2O . As mentioned above, the increase in the N_2O peak seems contradictory, at first, especially since the formation of O_2 is severely suppressed. One possible explanation could be that the formation of N_2O is effectively suppressed, and its concentration decreases, but this is masked in the FTIR spectra due to interferences from other compounds. Indeed, HNCO ($2254\text{--}2268 \text{ cm}^{-1}$),^{30,31} NCO (2175 cm^{-1})³¹ and $\text{NCO} + \text{OH}$ interactions (2237 cm^{-1})³¹ have almost the same FTIR bands as N_2O (2233 cm^{-1}),²¹ making it likely that the increased peak in the range $2210\text{--}2250 \text{ cm}^{-1}$ is the result of an increase of the (H)NCO concentration, which masks the decrease of the N_2O concentration.

Another plausible explanation could be that, although the O_2 formation is suppressed, N_2O is being formed through new

different pathways, as a result of the formation of HCN and NH_3 . For high temperature conditions, this has been detailed in numerous studies found in the literature describing the combustion chemistry of (de-)NO_x (and fuel NO_x).^{11,12} In the next section we analyse whether this chemistry is also relevant for the current low temperature plasma process under study.

2.3. de-NO_x chemistry

Despite scavenging the reactive O species to suppress the NO_x and N_2O formation, the presence of a hydrogen source also leads to a variety of reactants (such as HCN and NH_3), leading, in turn, to the additional formation (or destruction) of NO_x or N_2O . Fig. 4 gives a visual representation of how, at low temperature, a general NO_x reaction scheme of these interactions might look like, for $\text{CO}_2 : \text{N}_2$ plasma with the addition of CH_4 . It is important to note that this reaction scheme is only of a general character. It is based on the products observed with FTIR and on the most important reactions, defined by their rate coefficients presented in Section 2.4 of the ESI.† To construct an accurate fully supported chemical pathway, it is necessary to build a complete plasma chemical kinetics model that includes a detailed description of the NO_x and by-product chemistry, supported and validated by an extensive quantitative experimental study. For which the current analysis, together with the recent work of Wang *et al.*,¹⁶ can already provide a foundation.

We can summarize the reaction scheme as follows: HCN is formed from reactions of N and NO with CH_x and its concentration increases linearly (Fig. 3b) due to the absence of

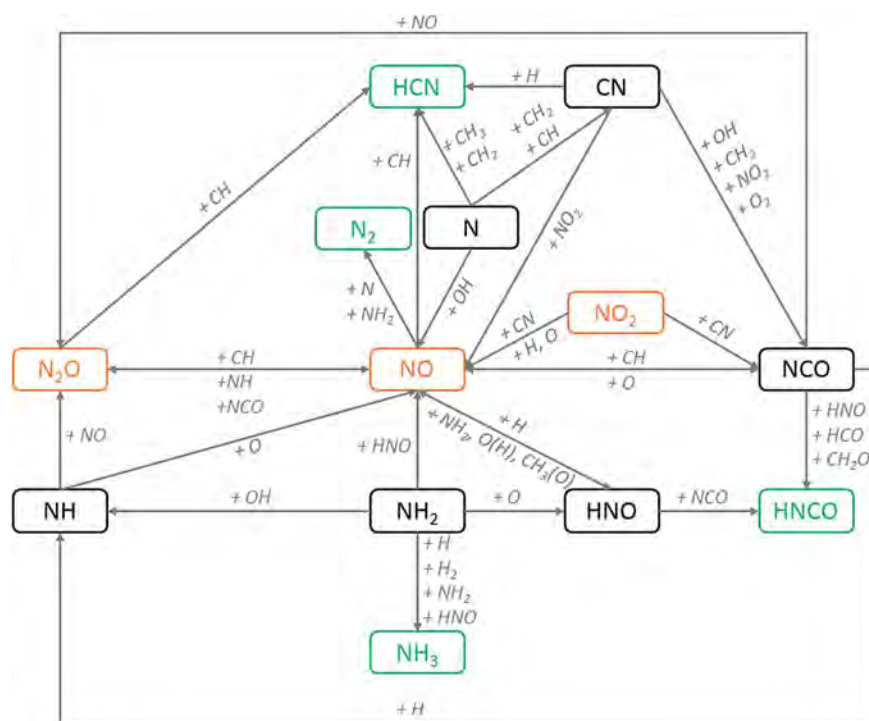


Fig. 4 Basic visual representation of a low temperature NO_x reaction scheme for $\text{CO}_2 : \text{N}_2$ plasma with addition of CH_4 (based on the most important reaction rate coefficients presented in Section 2.4 of the ESI†). For double-sided arrows, reactants above the arrows are those for reactions going from right to left, while reactants below the arrows are those for reactions going from left to right. NO_x and N_2O are marked in orange, whereas stable products without important loss processes are marked in green.

important destruction reactions (contrary to what is found in combustion processes). The formation of NH_3 , on the other hand, is delayed until an excess of CH_4 is added to the mixture (Fig. 3b), due to the consumption of the NH_x precursors through a reaction with either NO (to form N_2 and N_2O) or O (to form HNO). The formation of CH_3OH is also delayed until an excess of CH_4 is added to the mixture (Fig. 3b), probably due to the consumption of CH_x in the de- NO_x chemistry. Upon addition of CH_4 , the NO_2 concentration decreases more than the NO concentration (Fig. 3a) due to the interconversion of NO_2 into NO through reactions with H and O , and due to the formation of NO through several reactions starting from NH_x , HNO and NCO . Nevertheless, the NO concentration continues to decrease, due to destruction reactions with NH_x , CH and H . Finally, N_2O is formed from NO through reactions with NH and NCO , and destroyed by CH , whereas HNCO is formed by reaction of NCO with HCO , HNO and CH_2O , indicating that HNCO is a stable end-product, and that N_2O is converted into HCN as a stable end-product. As a result, the N_2O concentration most likely decreases and the increased peak at 2233 cm^{-1} (Fig. 2) is, in fact, due to the formation of HNCO , rather than an increase in N_2O concentration.

3. Discussion and outlook

We have demonstrated that it is possible to reduce the amount of NO_x produced during plasma-based CO_2 splitting in the presence of N_2 simply by adding a hydrogen source such as CH_4 , leading to the almost stoichiometric *in situ* trapping of oxygen. Adding CH_4 at 1 mol% of the total mixture yields NO_2 and NO FTIR absorbance peaks that are 82% and 51% lower than those obtained without the addition of CH_4 . Even higher reductions, up to 96% and 63%, are possible when a stoichiometric excess of the hydrogen source is added, which was 2 mol% CH_4 in our case. However, in that case, the excess hydrogen and carbon radicals will lead to the regular plasma-based reforming chemistry, creating several by-products in low concentrations, such as NH_3 , HCN , CH_3OH and probably HNCO .

From the data analysis it becomes clear that two processes are responsible for reducing the amount of NO_x produced. The first one is—the process we were aiming for—the direct inhibition of NO_x formation through the fast oxygen scavenging chemistry by the H and CH_x radicals, arising from the introduced CH_4 . The second one is the known reduction of NO_x to N_2 in the presence of reducing agents, in this case occurring at room temperature.

These findings suggest that impure CO_2 mixtures containing N_2 may be used as a feedstock, which could have a significant positive impact on the implementation of plasma-based CO_2 conversion research. As a result, there are several interesting follow-up questions. In the present study, we used the most convenient source of hydrogen, CH_4 , but it would be interesting to investigate other hydrogen sources.¹⁴ The most fundamental one would be H_2 , which could theoretically result in fewer by-products (*cf.* chemical analysis above). However, we could also look into greener and more sustainable hydrogen sources, such as glycerol.³² From the analysis side, an important challenge to

be addressed in future studies is the issue of N_2O and $(\text{H})\text{NCO}$ identification. Higher resolution FTIR, or separate N_2O detection using a customized GC (with TCD, ECD, NPD or MS) or custom sensors, might offer a solution.

Additionally, to capture the complete complexity of the underlying mechanisms and to be able to fully analyse and comprehend all the chemical pathways, it will be necessary to build a complete plasma chemical kinetics model with a detailed NO_x and by-product chemistry, supported and validated by a wide range of experiments. A good starting point for the development of such a model would be to expand the NO_x chemistry from Wang *et al.*'s recent work on $\text{CO}_2/\text{CH}_4/\text{N}_2$ mixtures.¹⁶

It would also be interesting to see whether the same effect can be found for different plasma types, especially for microwave (MW) and gliding arc (GA) plasmas. For these plasmas, the formation of NO_x is much higher, and the dominant pathway proceeds through vibrationally excited N_2 states, rather than through the metastable N_2 state and N radicals.^{9,10}

Finally, these results are a clear indication that the plasma chemistry can be controlled to a certain extent by adding small amounts of additives; a similar demonstration has been given by Snoeckx *et al.*³³ in their work on the selective formation of methanol. Despite the seeming trivialness of this insight, directing more research towards simple chemical intervention steps—before turning to complex engineering or plasma-catalysis combinations—could lead to short-term promising advancements in the field of plasma-based CO_2 conversion and hydrocarbon reforming.

Conflicts of interest

There are no conflicts to declare.

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